

BRS L7 6221 ((coeff\$8 with therm\$6 with expan\$6) or CTE) with silicon  
 USPAT; US-PGPUB 2004/01/10 17:34 0  
 BRS L8 175 ((coeff\$8 with therm\$6 with expan\$6) or CTE) with silicon with  
 value USPAT; US-PGPUB 2004/01/10 17:39 0  
 BRS L9 395 ((coeff\$8 with therm\$6 with expan\$6) or CTE) with gold  
 USPAT; US-PGPUB 2004/01/10 17:47 0  
 BRS L10 15 ((coeff\$8 with therm\$6 with expan\$6) or CTE) same (dielectric\$6  
 with (layer\$4 or stack\$6) with mirror) USPAT; US-PGPUB 2004/01/10 18:16  
 0  
 BRS L11 1 6525880.pn. USPAT; US-PGPUB 2004/01/10 18:09  
 0  
 BRS L12 1 6525880.pn. and (mirror same coat\$6) USPAT; US-PGPUB  
 2004/01/10 18:13 0  
 BRS L13 1558 mirror with coat\$6 with dielectric USPAT; US-PGPUB  
 2004/01/10 18:14 0  
 BRS L14 144 13 and 385/\$.ccls. USPAT; US-PGPUB 2004/01/10 18:14  
 0  
 BRS L15 46 13 and (mirror same (coeff\$8 with therm\$6 with expan\$6))  
 USPAT; US-PGPUB 2004/01/10 18:17 0  
 BRS L22 2488 385/16.ccls. or 385/18.ccls. or 385/47.ccls. or 359/578.ccls.  
 USPAT; US-PGPUB 2004/01/10 19:10 0  
  
 BRS 0 (MEM with dop\$6 with curv\$6) same mirrorUSPAT 2004/01/09  
 10:39 0  
 BRS 106 MEM with dop\$6 USPAT 2004/01/09 10:28  
 0  
 BRS 18 (MEM with dop\$6) and (mirror or relect\$6) USPAT 2003/09/12  
 15:23 0  
 BRS 1 MEM with dop\$6 with curv\$6 USPAT 2003/09/12 15:23  
 0  
 BRS 1 ((MEMS or MOEMS) same (mirror\$4 or reflect\$7 or HR)) and ((mirror\$4  
 or reflect\$7 or HR) with (micrometer or ".mu."\$8)) and (curvature with radius)  
 USPAT 2004/01/08 11:41 0  
 BRS 9 ((MEMS or MOEMS) same (mirror\$4 or reflect\$7 or HR)) and ((mirror\$4  
 or reflect\$7 or HR) with (micrometer or ".mu."\$8)) and (curvature with radius)  
 USPAT; US-PGPUB 2004/01/08 12:54 0  
 BRS 1 "20030138213" USPAT; US-PGPUB 2004/01/08 11:51  
 0  
 BRS 9 ((MEMS or MOEMS) same (mirror\$4 or reflect\$7 or HR)) and ((mirror\$4  
 or reflect\$7 or HR) with (micrometer or ".mu.m")) and (curvature with radius)  
 USPAT; US-PGPUB 2004/01/08 12:56 0  
 BRS 7 (((MEMS or MOEMS) same (mirror\$4 or reflect\$7 or HR)) and  
 ((mirror\$4 or reflect\$7 or HR) with (micrometer or ".mu.m")) and (curvature with  
 radius)) and ".mu.m" USPAT; US-PGPUB 2004/01/08 12:56 0  
 BRS 7 (((MEMS or MOEMS) same (mirror\$4 or reflect\$7 or HR)) and  
 ((mirror\$4 or reflect\$7 or HR) with (micrometer or ".mu.m")) and (curvature with

radius)) and "mu.m"\$8      USPAT; US-PGPUB 2004/01/10 17:33  
0  
BRS 1      6525880.pn.      USPAT; US-PGPUB 2004/01/08 14:27  
0  
BRS 2      (coat\$6 with layer\$6) and (MEMS or MOEMS) and ((process or method) with (mak\$6 or fabricat\$6 or manufactur\$6)) and (etch\$8 with layer\$6) and (dop\$6 with curv\$7)      USPAT      2004/01/09 10:14      0  
BRS 5      (coat\$6 with layer\$6) and (MEMS or MOEMS) and ((process or method) with (mak\$6 or fabricat\$6 or manufactur\$6)) and (etch\$8 with layer\$6) and (dop\$6 with curv\$7)      USPAT; US-PGPUB 2004/01/09 10:15      0  
BRS 8      (coat\$6 with layer\$6) and (MEMS or MOEMS) and ((process or method) with (mak\$6 or fabricat\$6 or manufactur\$6)) and (etch\$8 with layer\$6) and (dop\$6 with curv\$7)      USPAT; US-PGPUB 2004/01/09 10:16      0  
BRS 1      ((MEM or MOEM) with dop\$6) with ((curv\$6 or bend\$6) with (substrat\$6 or wafer\$6))      USPAT      2004/01/09 10:45      0  
BRS 510      (coat\$6 with layer\$6) and (MEMS or MOEMS) and ((process or method) with (mak\$6 or fabricat\$6 or manufactur\$6)) and (etch\$8 with layer\$6)      USPAT      2004/01/09 10:31      0  
BRS 1005      (coat\$6 with layer\$6) and (MEMS or MOEMS) and ((process or method) with (mak\$6 or fabricat\$6 or manufactur\$6)) and (etch\$8 with layer\$6)      USPAT; US-PGPUB      2004/01/09 10:45      0  
BRS 22      (MEMS or Moems) and (dop\$6 with curvature)      USPAT; US-PGPUB      2004/01/09 10:40      0  
BRS 161      (coat\$6 with layer\$6) and (MEMS or MOEMS) and ((process or method) with (mak\$6 or fabricat\$6 or manufactur\$6)) and (etch\$8 with layer\$6) and ((curv\$6 or bend\$6) with (substrat\$6 or wafer\$6))      USPAT; US-PGPUB 2004/01/09 11:07  
0  
BRS 123      ((coat\$6 with layer\$6) and (MEMS or MOEMS) and ((process or method) with (mak\$6 or fabricat\$6 or manufactur\$6)) and (etch\$8 with layer\$6) and ((curv\$6 or bend\$6) with (substrat\$6 or wafer\$6))) and (mirror\$4 or reflect\$8)      USPAT; US-PGPUB      2004/01/09 11:07      0  
BRS 51      ((coat\$6 with layer\$6) and (MEMS or MOEMS) and ((process or method) with (mak\$6 or fabricat\$6 or manufactur\$6)) and (etch\$8 with layer\$6) and ((curv\$6 or bend\$6) with (substrat\$6 or wafer\$6))) and (mirror\$4 or reflect\$8) and (dop\$6 same substrate)      USPAT; US-PGPUB 2004/01/09 11:25      0  
BRS 25      ryf.in.      USPAT; US-PGPUB 2004/01/09 14:09      0  
BRS 1      5618474.pn.      USPAT; US-PGPUB 2004/01/09 14:09  
0